



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Appl. No.	:	10/023,825	Confirmation No.	8239
Applicant	:	Jorge A. Kittl et al.		
Filed	:	12/19/2001		
TC/A.U.	:	2829		
Examiner	:	Russell M. Kobert		
Docket No.	:	TI-23892		
Customer No.	:	23494		
Title	:	METHOD TO IMPROVE SILICIDE FORMATION ON POLYSILICON		

RESPONSE AND AMENDMENT UNDER 37 CFR 1.111

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

MAILING CERTIFICATE UNDER 37 C.F.R. §1.8(A)
I hereby certify that the above correspondence is being deposited with the U.S. Postal Service as First Class Mail in an envelope addressed to: Assistant Commissioner of Patents, Washington, D.C. 20231.

Date

3-17-04

Marianna Smith
Marianna Smith

The following amendments and remarks are offered in response to the Examiner's Office Action dated 03/05/2004. They are respectfully submitted as a full and complete response to that Action.

Please amend the above-referenced application as follows:

Amendments to the ABSTRACT begin on page 2.

Amendments to the Claims are reflected in the listing of claims that begin on page 3 of this paper.

There are no **Amendments to the Drawings**.

The **Remarks** begin on page 5.